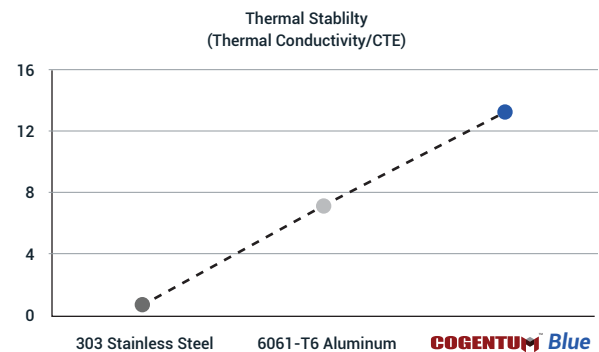


## ENABLING TECHNOLOGY FOR HIGH PERFORMANCE **SYSTEM ACCURACY**

Manufacturers of advanced back end semiconductor processing equipment are focused on providing their customers with innovative, high performance and cost effective solutions to maintain leading edge and competitive market positions. To maintain a technical leadership position, **system accuracy and precision** are critical aspects of any advanced machine design.

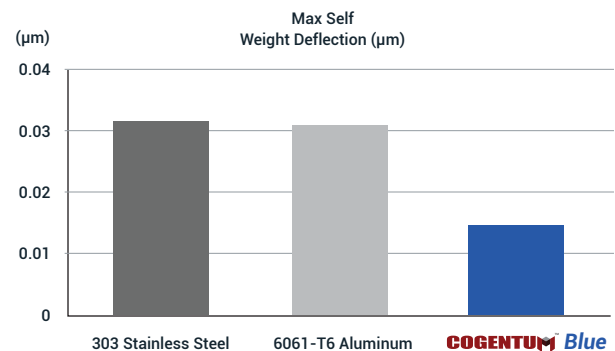
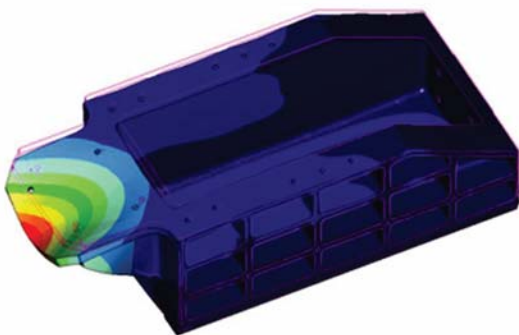
### SPECIFIC STIFFNESS AND THERMAL STABILITY

The **COGENTUM™** product line of advanced materials provides designers with the flexibility to optimize the **specific stiffness and thermal stability**: a component's high specific stiffness enables **precise and accurate** motion in advanced system design. High thermal stability is a function of a material's low coefficient of thermal expansion and high thermal conductivity and ensures positional **precision and accuracy** regardless of thermal micro-climates. Compared to traditional materials, combines both high specific stiffness and high thermal stability to enable **precise and accurate** advanced machine performance.



### DEFLECTION

Components and structures designed for **precision and accuracy** in advanced machine designs depend on material characteristics such as density (weight) and modulus (stiffness). A light weight but stiff material will minimize both self-weight and loaded deflections. **COGENTUM™** provides designers with the flexibility to design for minimal deflection without sacrificing other critical aspects of high performance machines.



[www.mmmt.com](http://www.mmmt.com)



## THE CLEAR MATERIAL CHOICE FOR ADVANCED MACHINE DESIGN

Material Property	COGENTUM™ Black	COGENTUM™ Blue	COGENTUM™ Gold
Density (g/cc) [ $\rho$ ]	2.78	2.80	2.96
Poisson's Ratio	0.29	0.29	0.25
Young's Modulus - GPa (E)	125	143	200
CTE avg 20-100°C(ppm/k) [ $\alpha$ ]	15	12	11
Thermal Conductivity (W/mK) [k]	160	164	160
Specific Heat(J/kg-K)	820	800	730
Ultimate Tensile Strength (MPa)	370	320	340
Fracture Toughness (MPa-m <sup>1/2</sup> )	15	13	13
Damping Factor(% Zeta)	0.26	0.26	0.58
Specific Stiffness(E/ $\rho$ )	45	51	68
Thermal Stability(k/ $\alpha$ )	11	14	14

### SEMICONDUCTOR BACK END OF LINE PRODUCT EXAMPLES

STAGE STRUCTURES & ASSEMBLIES



WAFER HANDLING COMPONENTS



Call or write today!

**M**aterials, **M**achining, **M**otion

[www.mmmt.com](http://www.mmmt.com)